	L #	Hits	Search Text
1	L1	1	("5191200").PN.
2	L2	; 1 1	(least adj square) and 6208407.pn.
3	L3	174780	(mask or reticle)
4	L4	174780	(mask or reticle)
5	L5	45248	(substrate or wafer) with (table or stage)
6	L6	11508	(substrate or wafer) same (position\$3 or measur\$4) same (height or focus)
7	L7	2034	4 and 5 and 6
8	L8		(reference near4 (plane or surface)) same (position\$3 or measur\$4)
9	L9	408	7 and 8
10	L10	224	9 and (355/\$.ccls. or 356/399-401.ccls. or 310/12.ccls.)
11	L11		(substrate or wafer) same (position\$3 or measur\$4) same (station or area or region)
12	L12	193	10 and 11

PK 12/27/02,